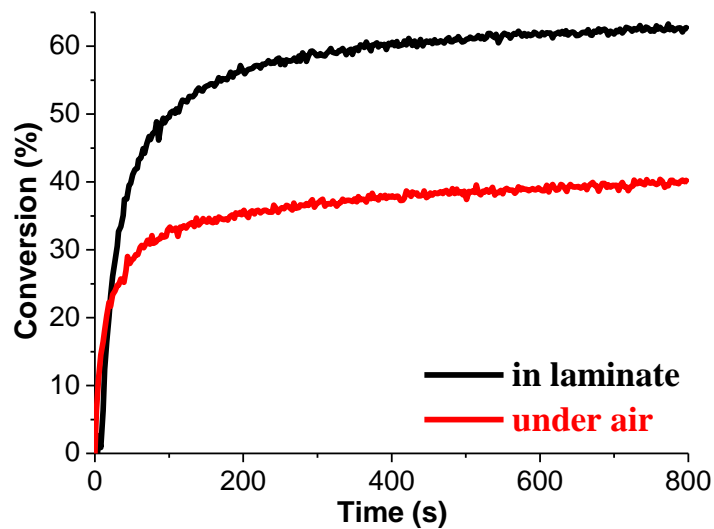


Supporting Information:

## Naphthalimide Based Methacrylated Photoinitiators in Radical and Cationic Photopolymerization under Visible Light

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**Figure S1.** Photopolymerization profiles of Ebecryl 605 (from Cytec) in the presence of MANA\_1/Iod/NVK (1%/2%/3%, w/w/w) in laminate and under air upon the laser diode at 457 nm exposure.